



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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PATENT #6
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Applicant : Kurt G. Steiner, et al.
Application No. : 10/038,352
Filed : January 2, 2002
Title : STRUCTURE AND METHOD FOR ISOLATING POROUS
LOW-K DIELECTRIC FILMS
Grp./Div. : 2812
Examiner : H.T. Nguyen/L.A. Gurley
Docket No. : 47071/MJM/A717

RESPONSE TO RESTRICTION REQUIREMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Post Office Box 7068
Pasadena, CA 91109-7068
September 10, 2002

Commissioner:

In response to the Office action (Restriction Requirement) dated August 8, 2002, applicants acknowledge the Examiner's requirement of restriction in the above-identified application and hereby elect Group II claims (claims 1-17) drawn to a semiconductor device, classified in class 257, subclass 760+, for the purposes of further prosecuting this patent application. This election is made without traverse.

In view of such election, applicants respectfully request that claims 1-17 be examined on the merits.

A Petition for One Month Extension of Time and the appropriate fee are enclosed herewith.

Respectfully submitted,
CHRISTIE, PARKER & HALE, LLP

By

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